

Title (en)

Method and apparatus for exposing a photosensitive material

Title (de)

Verfahren und Apparat zum Belichten von lichtempfindlichem Material

Title (fr)

Procédé et appareil pour l'exposition d'un matériau photosensible

Publication

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Application

EP 99202942 A 19990909

Priority

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Abstract (en)

The invention relates to a method and apparatus for exposing a photosensitive material such as colour negative film, colour reversal film and colour photographic paper, for evaluating the photographic characteristics of said photosensitive material. At least two different areas of the material are exposed differently and at least one light beam is used. At least one light beam is split into at least first and second parts which are equal to each other. At least two different areas are respectively exposed to the first part of the said light beam and the second part of the said light beam.

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IPC 8 full level

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CPC (source: EP)

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Citation (search report)

- [X] FR 2191756 A5 19740201 - SAMUELSON FILM SERVICE LTD [GB]
- [X] EP 0697288 A2 19960221 - EASTMAN KODAK CO [US]
- [A] US 5424802 A 19950613 - SAITA HIROFUMI [JP]
- [A] FR 2223724 A1 19741025 - KLIMSCH & CO [DE]

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